



The effect of gas mixing on the afterglow transient of beams extracted from an electron cyclotron resonance ion source

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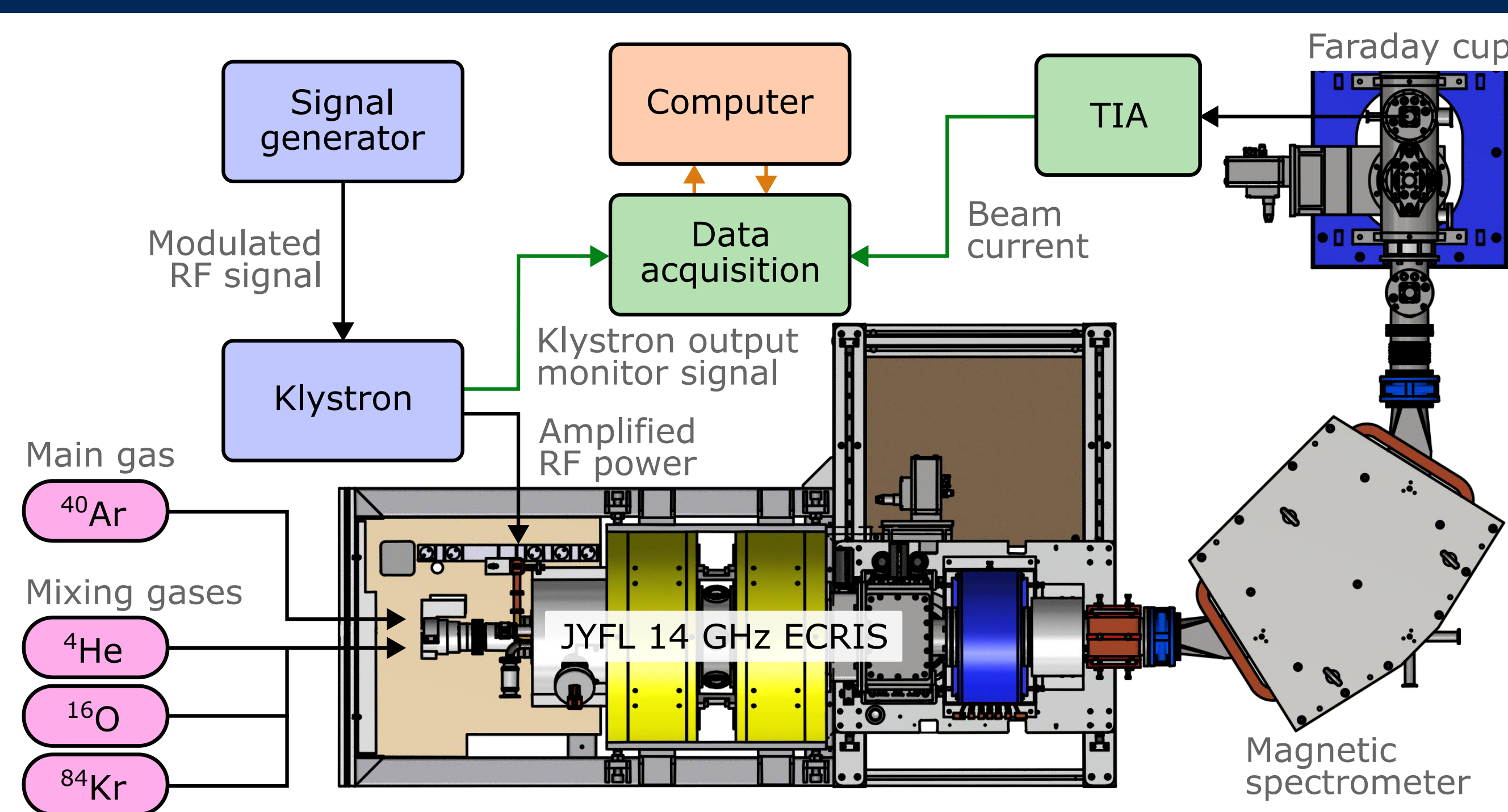
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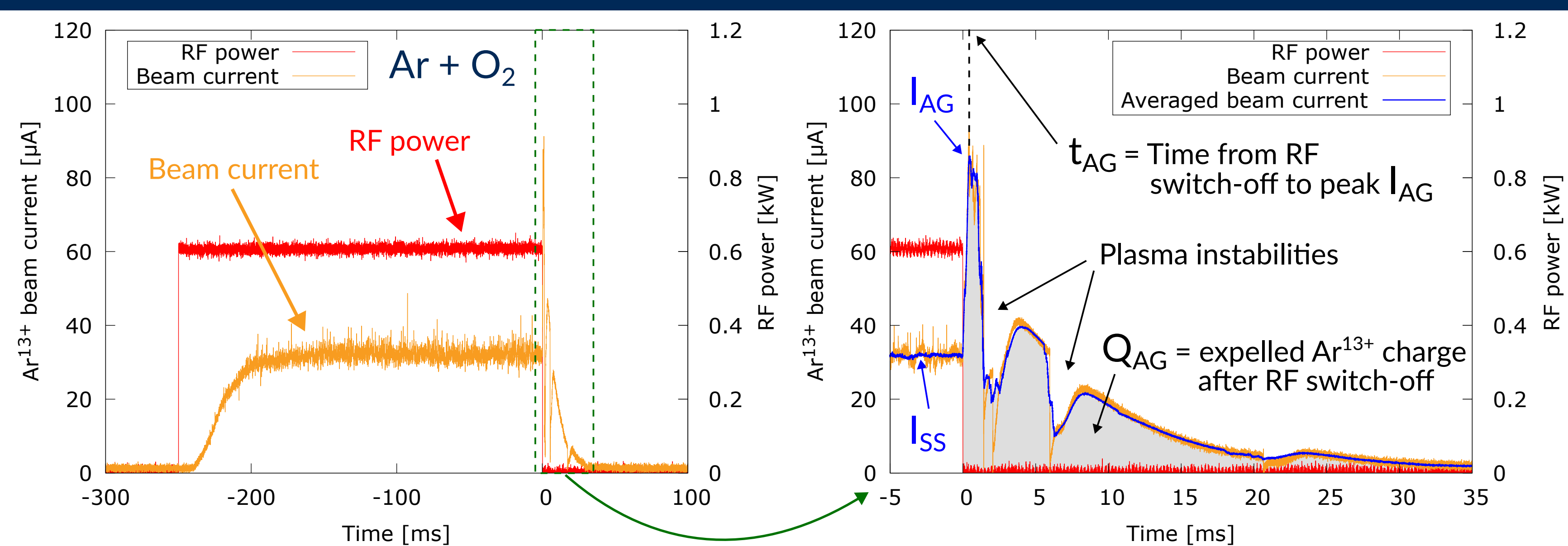
INTRODUCTION

- **Gas mixing** and **afterglow (AG) operation** are prominent methods with ECR ion sources to optimize extracted beam currents of highly charged ions.
- **Gas mixing**: a light gas species is introduced to plasma to boost the performance of a heavier main element. Effect is attributed to "cooling" of heavier element ions through collisions, leading to longer ion confinement times and consequently improved high charge state production.
- **Afterglow**: pulsing of plasma heating RF power leads to an intense short burst of high charge state ions following the RF switch-off. Effect is attributed to change of ion confinement scheme from ambipolar potential dip confinement to diffusive losses.
- Both methods are connected to ion confinement. **This work** probes this connection by studying **the effects of gas mixing on the properties of high charge state ion beams** (magnitudes and temporal structure) extracted from an ECRIS operated **in afterglow mode**.

EXPERIMENTAL SETUP AND PROCEDURE



- Ion source optimized for Ar^{13+} , which was used to probe high charge state ion behaviour.
- ^{40}Ar used as main gas, ^4He , ^{16}O and ^{84}Kr used as mixing gases.
- RF power pulsed at 2 Hz with 50% duty factor (250 ms ON/OFF).
- To account for pulse-to-pulse variations, up to 20 pulses were measured and averaged to determine beam current behaviour.

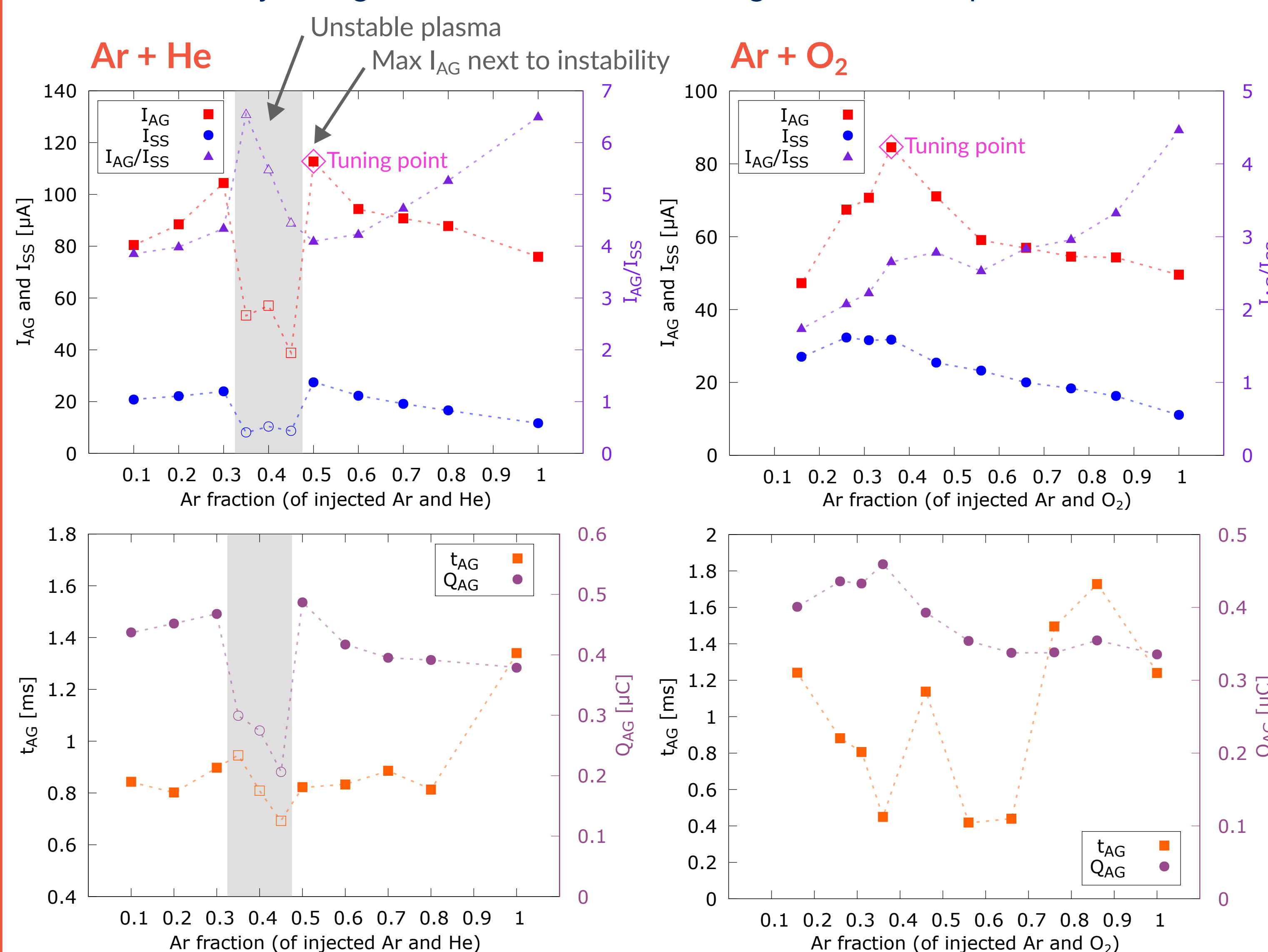


- **Studies:** (1) Effect of gas mixing on afterglow, (2) Effect of tuning; optimized CW beam current vs optimized AG peak current.
- **Procedure:**
 - Baseline measurement with pure Ar
 - Optimize Ar^{13+} in CW mode, set RF to pulsing → Measure AG properties
 - Optimize I_{AG} in pulsed mode → Measure AG properties
 - Gas mixing measurements, repeated with Ar+He, Ar+O₂, Ar+Kr
 - As above
 - Vary gas mixing ratio → Measure AG properties

EXPERIMENTAL RESULTS AND DISCUSSION

1 Gas mixing with varied mixing ratio

Ar fraction of injected gases varied while maintaining constant total pressure



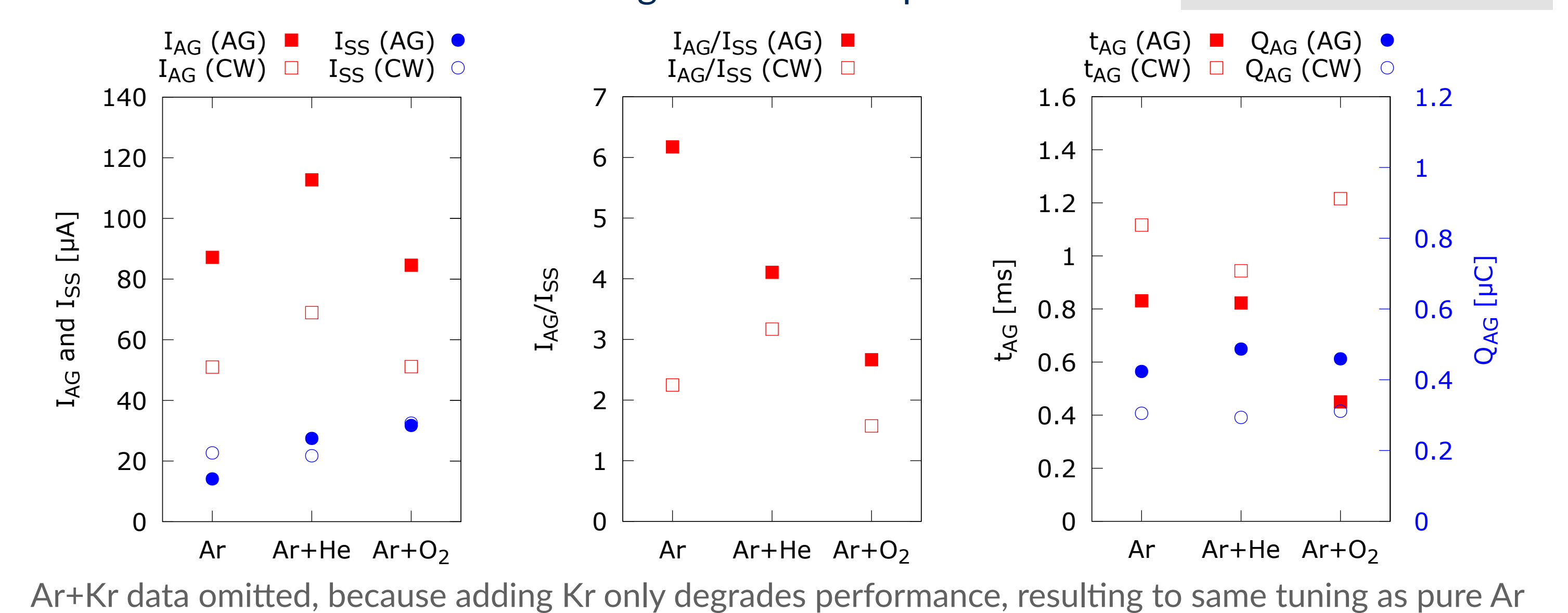
Ar + Kr (inverse gas mixing)

Adding any Kr only degrades performance, resulting to steady decrease of I_{AG} , I_{SS} , $I_{\text{AG}}/I_{\text{SS}}$ and Q_{AG} , and increase in t_{AG} .

2 CW tune versus AG tune

CW = Tuned for maximum Ar^{13+} current in CW mode
AG = Tuned for maximum Ar^{13+} afterglow current in pulsed mode

Main difference: AG tune has higher B fields and lower gas feed



Ar+Kr data omitted, because adding Kr only degrades performance, resulting to same tuning as pure Ar

Conclusions and discussion

Observations:

- Afterglow performance (i.e. I_{AG} , Q_{AG}) can be improved with gas mixing
- Highest I_{AG} with gas mixing, but highest $I_{\text{AG}}/I_{\text{SS}}$ with pure Ar
- Max I_{AG} coincides with high Q_{AG} and low t_{AG} , i.e. potential dip disappears faster and the dip confined population is larger when optimized for AG

Question: are effects due to changing ion density/production or confinement?

- Extracted current behaviour can be described with the following eqs.:

$$I_i^q \propto \frac{n_i^q}{\tau} \quad \text{and} \quad \frac{I_{\text{AG}}}{I_{\text{SS}}} = \frac{n_i^q / \tau(\Delta\phi \rightarrow 0)}{n_i^q / \tau(\Delta\phi)} = \frac{e^{\frac{q\Delta\phi}{T_i}}}{e^{\frac{q(\Delta\phi \rightarrow 0)}{T_i}}} = e^{\frac{q\Delta\phi}{T_i}}$$

- **Future:** measurement of light emitted by high charge state ions in plasma (intensity, emission line broadening) provides information about n_i and T_i
- When combined with the presented measurements, one can resolve the behaviour of τ and $\Delta\phi$ and determine whether the observed effects are caused by changing ion density/production or ion confinement in plasma